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Composition at the CuInSe₂ – ZnO interface: copper-depletion induced by diethyl-zinc

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Dedicated to Wolfram Jaegermann on the occasion of his 60th birthday.

Abstract

The interface formation between epitaxial $CuInSe_2(112)$ films and ZnO deposited by metal-organic MBE is investigated by photoelectron spectroscopy. Reaction of diethyl-zinc with $CuInSe_2$ leads to the formation of an intrinsic ZnSe layer and copper-depletion of the interface. This is associated with Zn doping of the chalcopyrite surface and a Fermi level shift towards the conduction band. The implications on the band alignment are discussed.

1. Introduction

One of the basic requirements to obtain highly efficient chalcopyrite solar cells is a buffer layer between the absorber and the sputtered ZnO window.¹ For one, the buffer is necessary to prevent shunts between front and back contact, but mainly to provide a good structural and electronic contact between absorber and window material. Hence, the interface should exhibit minimum recombination and current loss and allow for maximum open circuit voltage.^{2,3}

A good structural contact is achieved by using lattice-matched materials and can be further improved by interdiffusion during contact formation. This also results in a good electronic contact since only few structural defect states are present. In addition, the respective positions of electronic bands of the two materials should allow lossless electronic transport and simultaneously not decrease the open circuit voltage. These band offsets are in turn influenced by interface defects and interface dipoles. The detailed progression of valence and conduction band edges is also influenced by interfacial intermixing.⁴

As a model to describe the low interface recombination for chalcopyrite solar cells with CdS buffer, the concept of a buried homojunction inside the absorber has been discussed. ^{5,6}_A Here, the Fermi level position is shifted from the valence band (p-type) for the bulk of the absorber towards the conduction band at the interface (n-type). This could be achieved either during the absorber growth process, with Cu-poor conditions during final growth sequence, or induced by contact formation with the buffer. In this case, the buffer material should facilitate the type

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Apparently, the type inversion is associated with a copper-depletion forming a n-type <u>CuInSe₂</u> <u>layer close to the</u> interface region. For one, surfaces of efficient absorbers are itself copperdepleted with respect to the bulk material. However, recent experiments on polycrystalline and epitaxial chalcopyrite have shown that the intrinsic copper depletion of the surface is restricted to the top few atomic layers and can be understood as a surface reconstruction.^{7,8}

In addition, copper-depletion in CuInSe₂ is caused by a self-compensation mechanism induced by n-type doping. For the chemical bath deposited (CBD) CdS buffer, doping of the chalcopyrite by Cd_{Cu} defects was observed.^{9,10} The concomitant Fermi level shift leads to spontaneous formation of V_{Cu} defects, which compensate for the increased electron density.¹¹ This mechanism creates interstitial Cu_i defects, which show a high mobility due to diffusion in CuInSe₂.¹²

Although the CBD-CdS is still the benchmark for high-efficiency cells, Cd-free alternatives that are deposited in a dry vacuum process are being sought, as a complete in line vacuum process without wet-chemical treatments may be achieved ¹⁵. Frequently investigated are ZnO-based semiconductors, which offer the possibility to combine the functionality of a buffer layer and the i-ZnO layer in one film.¹³ Sputtered (Zn,Mg)O layers and ALD-deposited Zn(O,S) yielded efficiencies comparable to the CdS reference.¹⁴ $\frac{31}{4}$

In our recent publications, we suggested ZnO deposited by MOMBE (metal-organic molecular beam epitaxy) as a suitable buffer layer material, since it forms an intrinsic ZnSe/ZnS layer in the contact plane between CuInSe₂/CuInS₂ absorbers and ZnO with a favorable band alignment for photovoltaic applications.^{15,16} Here, we will further analyze the composition during deposition of MOMBE-ZnO and MBE-ZnSe on CuInSe₂ by photoelectron spectroscopy (PES). The focus will be on the formation of copper-poor phases in the chalcopyrite absorber. Implications on the resulting band alignment at the interface are discussed.

2. Experiment

CuInSe₂ samples were grown by MBE (molecular beam epitaxy) on GaAs(111)A substrates, which were wet-chemically etched prior to insertion into the UHV (ultra-high vacuum) system. Elemental Cu, In and Se were evaporated from effusion cells. At a substrate temperature of 525°C, the (Cu+In)/Se ratio is self-adjusting, if Se is provided in excess. The

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Cu/In ratio was selected by adjustment of the Cu flux. Stoichiometric CuInSe₂ surfaces and Cu-poor surfaces of the CuIn₃Se₅ defect compound could thus be obtained.

ZnO films were deposited by metal-organic MBE (MOMBE) from gaseous precursors DEZ (diethyl-zinc) (Sigma Aldrich) and water (ultra-purified and vacuum distiled) at chalcopyrite substrate temperatures ranging from $325 - 400^{\circ}$ C. The DEZ and H₂O partial pressures were 2×10^{-6} mbar and 8×10^{-6} mbar, respectively. ZnSe was deposited by evaporation of the compound from an effusion cell (MBE) at substrate temperatures of 300 and 350 °C.

To ensure contamination free sample surfaces, all preparation and analysis were carried out in our integrated UHV system with a base pressure in the 10⁻¹⁰ mbar range. The single crystalline structure and surface order were confirmed by LEED (low-energy electron diffraction). For sample characterization, depth profiles and band alignment measurements we used photoelectron spectroscopy with MgK_{*}, mono-AlK_{*} and HeI radiation and a SpecsPhoibos 150 electron analyzer equipped with a delay line detector.

<u>Cu/In ratios were obtained by fitting the appropriate lines (see Fig 1) and the relation</u> $\frac{C_{cu}}{S} = \frac{I_{cu}}{S} \cdot \frac{S_{cu}}{S} \text{ with } S_{\underline{Cu}} = 3.55 \text{ and } S_{\underline{In}} = 4.36 \text{ for } AlK_{\underline{a}} \text{ radiation } ^{32}.$ Angular dependent spectra

 C_{In} I_{In} S_{In} S_{In} S

2.6nm to 0.89 nm for Cu and from 3.2 to 1.2nm respectively for In changing the escape angle from 0° to 70°. The accuracy of the manipulator was checked by recording the ARUPS data for the Shokley surface state S1 of a Cu(111) sample to be better than 0.3°_{\star} .

<u>GaAs (111)</u> substrates were cleaned and etched in a H_2SO_4 - HCl- H_2O (2:2:5) solution for 20min. at 50°C and a sulfur termination in (NH₄)₂S solution for 30min at 60°C.

On the GaAs(111) surface, CuInSe₂ grows along its (112) direction and therefore with its low-energy surface. On flat substrates, these samples exhibit rotational domains, as indicated by the hexagonal LEED pattern. Near-stoichiometric surfaces show a $c(4\times2)$ reconstruction, indicating the chalcopyrite surface order (see Fig. 1). For copper-poor samples, the chalcopyrite surface order is absent, indicating short-range order of the cation sublattice.

For the band alignment and interface formation experiment, the ZnO/ZnSe films were deposited stepwise onto the CuInSe₂(112) substrate and the samples were subsequently characterized after each deposition cycle.

3. Results

3.1 ZnO buffer layer by MOMBE

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Christian Pettenkofer 20.1.14 15:32 Gelöscht: ⁸ Christian Pettenkofer 6.11.14 16:10 Formatiert: Schriftart:12 pt, Schriftfarbe: Text 1, Hochgestellt The core level photoemission lines in the course of ZnO deposition by MOMBE are shown in Fig. 2. It is apparent that Zn is present from the first deposition step on, while no oxygen is observed for the first two growth cycles. Like we reported earlier for the CuInSe₂(112) surface, this behavior can be understood in terms of an ultra-thin ZnSe buffer formed at the chalcopyrite surface by reaction of DEZ with the substrate chalcogenide $\frac{16}{4 \pi}$. This is indicated by the absence of the oxygen emission peak and the evolution of the Zn Auger parameter α_{Zn} . Here, the binding energy of the Zn 2p_{3/2} peak and the kinetic energy of the Zn LMM Auger emission are added, to give a more precise measure for the chemical environment of Zn atoms. A shift of α_{Zn} from 2011.9 eV typical for ZnSe to 2010.1 eV which is indicating a clean reaction of the precursors at the surface $\frac{33}{2}$.

The reaction of DEZ vapor with the chalcopyrite surface at elevated temperatures (T = $325 - 450^{\circ}$ C) is well-established for CuInS₂(112) $\stackrel{15}{\swarrow}$ poly-CuInS₂, CuInSe₂(112) and (001) $\stackrel{16}{\checkmark}$ substrates. Depending on the details of substrate composition and process parameters this ZnS/ZnSe layer reaches a thickness of 0.5 – 1.5 nm, as determined from the attenuation of the In3d signal.

The growth mode of ZnSe/ZnO can be monitored with LEED analysis. For stoichiometric chalcopyrite, the superstructure spots indicating the chalcopyrite surface order vanish after deposition of the Zn (Fig. 1). The resulting hexagonal pattern shows sharp spots indicative of epitaxial growth. This can be expected due to the close lattice constants of CuInSe₂ with 5.78 Å and 5.67 Å for ZnSe, which results in a small lattice mismatch of 1.9 %. The vanishing of superstructure spots could be interpreted as the formation of a ZnSe layer without long-range surface reconstruction order. However, for a Zn coverage in the sub-monolayer range, the absence of a superstructure can be understood in terms of a Cu-poor surface with CuIn₃Se₅ composition further denoted as ordered defect compound (ODC).

This type of compositional change, namely the reduction of the Cu/In ratio near the absorber/buffer interface, shall be considered here. The reaction of DEZ with the Se constitutes one mechanism of intermixing at the interface. Interaction of the water provided in the MOMBE process with chalcopyrite is apparently weak. For further interface reaction analysis, we will consider the composition in the *absorber* during ZnSe/ZnO layer growth.

For this purpose, we analyze the Cu/In ratio of photoemission intensities. Due to the use of MgK_a radiation, electrons ejected from Cu2p_{3/2} and In3d_{5/2} exhibit different inelastic mean free paths λ and therefore, according to the Lambert-Beers law I = I₀ e^{-d/_a}, are not uniformly

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damped by the ZnSe/ZnO layer. Assuming a uniform top layer of thickness d, the Cu/In intensity ratio is given by $I = I_0 e^{-d({}_{\lambda}In_{\lambda}Cu_{\lambda\alpha}Cu_{\lambda}In_{\lambda}}$. This corresponds to an exponential damping of the Cu/In intensity with increasing ZnSe/ZnO layer thickness, provided that the *actual* concentration ratio of Cu to In in the underlying absorber remains constant.

The Cu/In intensities for CuInSe₂(112) are plotted in Fig. 3, versus the ZnSe/ZnO layer thickness for MOMBE-ZnO growth on CuInSe₂ substrates. The layer thickness was determined from the attenuation of the In3d core level signal. The following features can be identified: 1. The Cu/In ratio drops suddenly for small amounts of Zn coverage for CuInSe₂ surface compositions around the stoichiometric point. This drop cannot be explained by the non-uniform damping of photoemission intensities, but is rather an indication of a change in the composition near the surface. 2. For substrates with ODC surface composition, the Cu/In intensities evolve according to the theoretical curve for uniform damping and unchanged composition. 3. By deposition of Zn from MOMBE, the Cu/In ratio near the surface/interface for CuInSe₂ approaches the curve for CuIn₃Se₅. The data presented here were recorded for the CuInSe₂(112). Note that the same behavior of the Cu/In ratio is observed for ZnO deposition on the CuInSe₂(001) surface.²⁴/_x Therefore, the copper depletion mechanism is regarded independent from the surface orientation.

The conclusion is the following: Deposition of small amounts of Zn on CuInSe₂ by exposure to DEZ at elevated temperatures (T \approx 350°C) leads to a reduction in Cu concentration near the surface and consequently the interface with ZnSe/ZnO. Here, the Cu/In ratio as observed in XPS approaches values that are indicative of the copper-deficient defect phase CuIn₃Se₅ (ODC).

Zn deposition onto the CuInSe₂ surface leads to band bending and therefore shifts the Fermi level position in the band gap. This can be understood in terms of n-type doping via Zn_{Cu} defects which is associated with a simultaneous formation of a ZnSe layer at the surface. The Fermi level shift towards the conduction band minimum (CBM) results in a lowering of the defect formation energies. Calculations by Persson *et al.* ¹⁷ revealed that the energy for V_{Cu} formation becomes exothermal for a Fermi level position at 0.95 eV from the VBM or equally 0.09 eV form the CBM. This leads to spontaneous formation of V_{Cu} defects and the associated diffusion of interstitial Cu away from the surface explains the observed copper depletion. This mechanism was first observed by Klein *et al.* on cleaved CuInSe₂ single crystals after deposition of CdS and Na¹¹/₂¹⁸

In order to obtain the Fermi level position in the band gap after exposure of $CuInSe_2$ to DEZ, we add the position of the VBM for the bare substrate to the band bending induced by Zn

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Christian Pettenkofer 6.11.14 16:10 Formatiert: Schriftart:12 pt, Schriftfarbe: Text 1, Hochgestellt Christian Pettenkofer 20.1.14 15:32 Gelöscht: ¹¹ deposition. Results obtained for the different near-stoichiometric samples are 1.02 eV and 0.93 eV for the In-rich and Cu-rich surface, respectively. This agrees nicely with the theoretical value for the threshold of spontaneous defect creation.

3.2 ZnSe buffer layer by MBE (PVD)

A similar experiment was conducted in order to elucidate the reaction of Zn with the substrate. Here, Zn was not provided in form of a reactive organo-metallic compound, but by evaporation from the ZnSe compound. ZnSe sublimes dissociatively, forming Zn and Se₂ in the gas phase.¹⁹ Therefore, roughly stoichiometric amounts of elemental Zn and Se impinge on the substrate surface. To facilitate epitaxial growth of ZnSe and for comparison with the MOMBE process, the substrate temperature was set to 300° for the Cu-rich and 350°C for the In-rich sample.

<u>To analyze the effect of elemental Zn on the CuInSe₂(112) surface, we first consider the Zn</u> Auger parameter. α_{Zn} remains effectively unchanged throughout the experiment at values around 2011.9 eV and is indicative of Zn-Se bonds. For increasing ZnSe layer thickness, the chalcopyrite superstructure spots in the LEED pattern vanish (Fig. 1).

Now, the evolution of the Cu/In ratio during the experiment shall be considered, to see if a Cu depletion similar to the MOMBE process occurs. During the first deposition steps, a slight reduction of the Cu/In compared to the uniform damping curve is observed. Hence, the onset of a Cu depletion is visible, albeit not as pronounced as for the MOMBE process, and Cu/In does *not* approach the ODC value. From ZnSe layer thicknesses of more than ≈ 1 nm on, Cu/In rises above the uniform damping curve. Even for ZnSe films that are thick compared to the XPS information depth, a Cu signal is still measureable. This indicates a (temperature driven) Cu migration from CuInSe₂ into the ZnSe layer at elevated temperatures. XPS depth profile measurements show that Cu concentration is enhanced at the surface of ZnSe. We therefore conclude that the Cu depletion near the CuInSe₂/ZnSe interface is superimposed with Cu diffusion into the ZnSe layer and segregation of a Cu-Zn-Se compound at the surface. Hence, the formation of an ODC near the interface could not be as clearly identified as for the case of MOMBE-ZnO deposition.

3.3 Concentration depth profile

In order to further analyze the copper depletion induced by the DEZ, compositional depth profiles have been recorded with angle-resolved XPS (x-ray PES). By variation of the detection angle θ relative to the surface normal, the surface sensitivity of XPS is increased

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After exposure to DEZ at 400°C substrate temperature, this curve appears shifted to lower Cu/In values. For one, this proofs the strong reduction of the overall Cu concentration due to the reaction with DEZ. Second, a strong copper gradient within a few atomic layers from the surface is still present. This means that a copper depletion of the near-surface region exists together with copper-poor interface structure. The formation of ZnSe bonds in the course of Zn deposition indicates that vacant Cu sites at the surface are filled by Zn atoms, thereby increasing the electron concentration at the surface. This could lead to a pinning of the Fermi level near the conduction band at the CuInSe₂/ZnSe interface.

4. Discussion

Doping of the CuInSe₂ surface is also observed for CBD-CdS buffer layers.²² PES depth profiles show that Cd is restricted to first atomic layers and depends on the availability of free sites, namely V_{Cu} . Therefore, one has to consider the interplay between doping, position of the Fermi level and defect formation. Doping shifts the Fermi level and causes additional copper depletion. The resulting stoichiometry for exposure to DEZ at elevated temperatures is that of the ordered defect compound. Therefore, we suggest the following structure for the CuInSe₂-ZnO interface (see Fig. 5): near the interface, the absorber is copper depleted with ODC composition and presumably Zn-doped, this region is termed Zn:CuIn₃Se₅. The attenuation of both the Cu and In signal before oxygen deposition requires the presence of a ZnSe phase on top of the copper-depleted region. Finally, pure ZnO is deposited in the MOMBE process. Annealing experiments reported earlier show that there is partial diffusion of In into the ZnO window.²³

With the knowledge about interdiffusion and the different phases present at the CuInSe₂-ZnO interface, the complete band diagram can be constructed. Here, we use values for the individual interfaces as determined from PES according to our previous publications $\frac{16}{x}$ ²⁴ ²⁵ ²⁵ Special care was taken to analyze the VBM of epitaxial CuInSe₂ correctly by considering the experimental valence band structure.²⁶ The valence band offset between stoichiometric CuInSe₂ and the ODC was determined in a separate experiment by direct growth of Cu-poor

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Christian Pettenkofer 6.11.14 16:10 Formatiert: Schriftart:12 pt, Schriftfarbe: Text 1, Hochgestellt Christian Pettenkofer 20.1.14 15:32 Gelöscht: ¹⁶ material on a CuInSe₂(112) substrate. By application of the transitivity rule, we obtain valence band discontinuities ΔE_V of 0.78 eV and 2.23 eV for CuInSe₂/ZnSe and CuInSe₂/ZnO interface, respectively. These results also agree nicely with theoretical values for the respective interfaces.^{27,28} However, it should be noted that, due to the intermixing at elevated temperatures, the interfaces are not atomically sharp. From the band diagram in Fig. 6, it is obvious that the conduction band lineup is favorable for electronic transport from the absorber to the ZnO window if the ZnSe layer remains thin enough for electrons to tunnel through.

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Apparently, the choice of buffer layer material and deposition process severely influences the composition and diffusion properties of the interface. Hereby, one can either promote or hinder copper depletion of the interface region. There are indications that copper accumulation, like it was observed for sputtered (Zn,Mg)O buffer layers reduces cell performance.²⁹ Most of the models describing highly efficient cells work with a buried p-n-hetero-junction inside the chalcopyrite absorber. The question is if a copper-depleted layer is necessary for the buried junction and to what extent this depletion is beneficial for the cell performance. Vacuum deposition methods offer a variety of possibilities to adjust the interface chemistry by the type of deposition process and process parameters. Recent investigations on ZnO buffer layers deposited with ALD indicate a copper-depletion of the interface **layer of ZnIn₂Se₄ is proposed, which is situated between the ODC and the ZnSe layer**.³⁰ Therefore, it would be insightful to study different deposition methods or the influence of the process temperature on copper-depletion to optimize the interface properties.

We have shown that a clear copper-depletion of the interface can be evoked by exposure of near-stoichiometric $CuInSe_2$ surfaces to DEZ at elevated temperatures. Therefore, interface properties can be adjusted deliberately by choice not only by the type of buffer material but also by the process type and processing parameters.



Fig. 1 LEED images for $CuInSe_2(112)$ substrates of varying Cu/In stoichiometry before and after deposition of a thin ZnSe layer as a interface reaction by ZnO-MOMBE and ZnSe-MBE. The chalcopyrite superstructure of near-stoichiometric samples vanishes due to Zn deposition.

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Fig. 2 X-ray photoemission spectra of the main core levels after each MOMBE-ZnO deposition step on a CuInSe₂(112) film. Note that no oxygen signal is present for the first two ZnO deposition steps. Layer thickness is evaluated from the attenuation of the In signal according to Lambert-Beer law.



Fig. 3 Evolution of the Cu/In signal ratio during MOMBE-ZnO (DEZ) and PVD-ZnSe grwoth on CuInSe₂ substrates with varying stoichiometry <u>derived from PES</u> <u>data in normal emission, layer thickness is derived from</u> <u>the attenuation of the In signal</u>. The black lines indicate the progression that is expected for uniform growth *without* diffusion or intermixing. Significant deviations are observed for near-stoichiometric samples. Christian Pettenkofer 20.1.14 15:10 Formatiert: Schriftart:9,5 pt, Fett, Schriftfarbe: Automatisch Christian Pettenkofer 20.1.14 15:10 Formatiert: Standard



Fig. 4, Depth profile of the Cu/In ratio recorded by angleresolved XPS using AlK, radiation. The bare CuInSe₂ substrate shows a copper-poor surface, indicated by a reduction of Cu/In for larger emission angles (increased surface sensitivity). After exposure to diethyl-zinc and formation of a 1.3 nm ZnSe layer, the curve appears shifted to lower Cu/In values due to copper-depletion and ODC formation.











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were calculated with the use of literature values of band gap energies.

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